	$Cu(NO_3)_2 \cdot 3H_2O$	H ₃ BTC	modulator
Cu-BTC_RT_10	0.014 M	0.009 M	0.14 M
Cu-BTC_RT_20	0.014 M	0.009 M	0.28 M

Table S1. Synthesis conditions of Cu-BTC_RT_x under room temperature synthesis.

Table S2. Synthesis conditions of Cu-BTC_y under solvothermal synthesis.

	$Cu(NO_3)_2 \cdot 3H_2O$	H ₃ BTC	modulator	
Cu-BTC_0	0.12 M	0.08 M	-	
Cu-BTC_2	0.12 M	0.08 M	0.24 M	
Cu-BTC_10	0.12 M	0.08 M	1.21 M	
Cu-BTC_20	0.12 M	0.08 M	2.43 M	

Materials	Deposition	Current	Coulombic	Cycle	Nucleation
	Capacity	Density	Efficiency	Number	Overpotential
	$(mA h cm^{-2})$	$(mA cm^{-2})$	(%)		(mV)
Crumpled Graphene ¹	1	0.5	97%	50	
Cu-CuO-Ni	1	1	95%	250	
hybrid structure ²					
Ag@NCS ³	4	0.5	98.6%	400	~1
AgNPs@Cu ⁴	1	1	94.5%	100	
CuO NAs/CF (MOF-	1	1	98%	180	30
derived CuO nanorod					
arrays on Cu foil					
current collector) ⁵					
Ag@HKUST-16	1	0.5	97%	300	3
	1	1	97.50%	50	
	5	1	98.50%	50	
Modulated	1	1	98.2%	520	0.6
CuBTC ^(This work)					
Ag@CuBTC(This work)	1	1	92.3%	70	

Table S3. Comparison of the cycling stability with the previously reported Li deposition.



Figure S1. Raman spectra of Cu-BTC_0 and Cu-BTC_10, and the corresponding silverdoped MOFs Ag@Cu-BTC_0 and Ag@Cu-BTC_10.



Figure S2. XPS (a) C 1s, (b) O 1s, (c) Cu 2p_{3/2}, and (d) Ag 3d spectra of Cu-BTC_0 and Cu-BTC_20, and the corresponding silver-doped MOF Ag@Cu-BTC_20.



Figure S3. The TEM image of Ag@Cu-BTC_10 (a), (b) HRTEM for Ag d-spacing, (c) STEM image, and (d-f) STEM-EDS mapping results.



Figure S4. The TEM image of Ag@Cu-BTC_0 (a), (b) HRTEM for Ag d-spacing, (c) STEM image, and (d-f) STEM-EDS mapping results.





Ra: 162 nm



Ra: 90 nm

Ra: 130 nm

Figure S5. AFM scans of (a-d) Cu-BTC_0, 2, 10, 20 electrodes.



Figure S6. Contact angles of electrolyte on the (a) Copper foil, (b-e) Cu-BTC_0, 2, 10, and 20 electrodes.



Figure S7. Contact angles of electrolyte on the (a) Ag@Cu-BTC_0 and (b) Ag@Cu-BTC_10 electrodes.

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